L Number	Hits	Search Text	DB	Time stamp
1	1	("5118485").PN.	USPAT;	2003/12/01 11:19
		, , , , , , , , , , , , , , , , , , , ,	US-PGPUB	2000, 20, 01 11119
2	93025	CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:20
			US-PGPUB	
3	96259	\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:54
1		(40 0000	US-PGPUB	
4	. 2	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:22
5	26	) same water with recycle	US-PGPUB	2002/12/01 11:04
*	. 20	(\$3CVD (chemical adj vapor adj deposition) ) and water with recycle	USPAT; US-PGPUB	2003/12/01 11:24
6	16	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:32
		) and direct\$3 with recycle	US-PGPUB	2003/12/01 11.32
7	16	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:32
		) with recycle	US-PGPUB	
8	52	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:36
		) with recycl\$4	US-PGPUB	
9	1	("4468283").PN.	USPAT;	2003/12/01 11:43
1.0			US-PGPUB	
10	0	(CVD (chemical adj vapor adj deposition))	USOCR	2003/12/01 11:44
11	12	with recycl\$4 (CVD (chemical adj vapor adj	USOCR	2002/12/01 21-47
	12	deposition))and recycl\$4	USUCK	2003/12/01 11:47
12	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:47
13	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:47
14	154	vapor with direct\$5 with recycle	USPAT;	2003/12/01 11:48
		•	US-PGPUB	
15	. 69	vapor with directly with recycle	USPAT;	2003/12/01 13:44
			US-PGPUB	
16	123	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:54
		) and recycl\$5 with water	US-PGPUB	
17	1683	/\$20VD /ohomical adi wanan adi danasitisan)	HODEN	0000/10/01 11 55
+ '	1000	<pre>(\$3CVD (chemical adj vapor adj deposition) ) and recycl\$5</pre>	USPAT: US-PGPUB	2003/12/01 11:55
		, and ledyclos	US-FGFUB	
18	31	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:42
		) and recycl\$5 with directly	US-PGPUB	] 2000, 22, 02 2012
19	15654	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:21
	100	) and (dipole polar\$7)	US-PGPUB	
20	196	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:21
21	13	) with (dipole polar\$7) ((\$3CVD (chemical adj vapor adj	US-PGPUB	2002/12/01 12:40
		deposition)	USPAT; US-PGPUB	2003/12/01 13:42
	·	) and recycl\$5 with directly	CD IGEOD	
		) and permeate		
22	8	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:47
		) with raw with recycl\$5	US-PGPUB	
23	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:48
1 24	_	) with unseparated with recycl\$5	US-PGPUB	
24	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:00
25	0	) and unseparated with recycl\$5 (\$3CVD (chemical adj vapor adj deposition)	US-PGPUB	2003/12/03 14 00
	3	) and untainted with recycl\$5	USPAT; US-PGPUB	2003/12/01 14:00
26	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:00
	İ	) and unprocess\$4 with recycl\$5	US-PGPUB	
27	17	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:15
		) and outlet with inlet with direct\$3	US-PGPUB	
	_	near2 (connect\$6)		
28	2	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:15
		) and outlet with inlet with direct\$3	US-PGPUB	
	<u>_</u>	near2 (coup1\$6)		